FORM 1449* INFORMATION DISCLOSURE STA	TEMENT	t Number: 1944USWO	Application Number: Unknown 10/598,095	
IN AN APPLICATION	Applica	Applicant: KITAOKA, et al.		
(Lice several cheets if necessar	v) Filing I	Date: Horowith	Group Art Unit: Hoteland 1792	

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING IF APPRO		
/F.H./	2004/183090	September, 2004	Kitaoka, et al.					
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		FOREIG	N PATENT DOCUM	IENTS				
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			<u> </u>			YES	NO	
F.H./	1-116013	May, 1989	Japan			Abstract		
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EXAMINER	/Felisa Hiteshew/	DATE CONSIDERED	12/21/2007

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.